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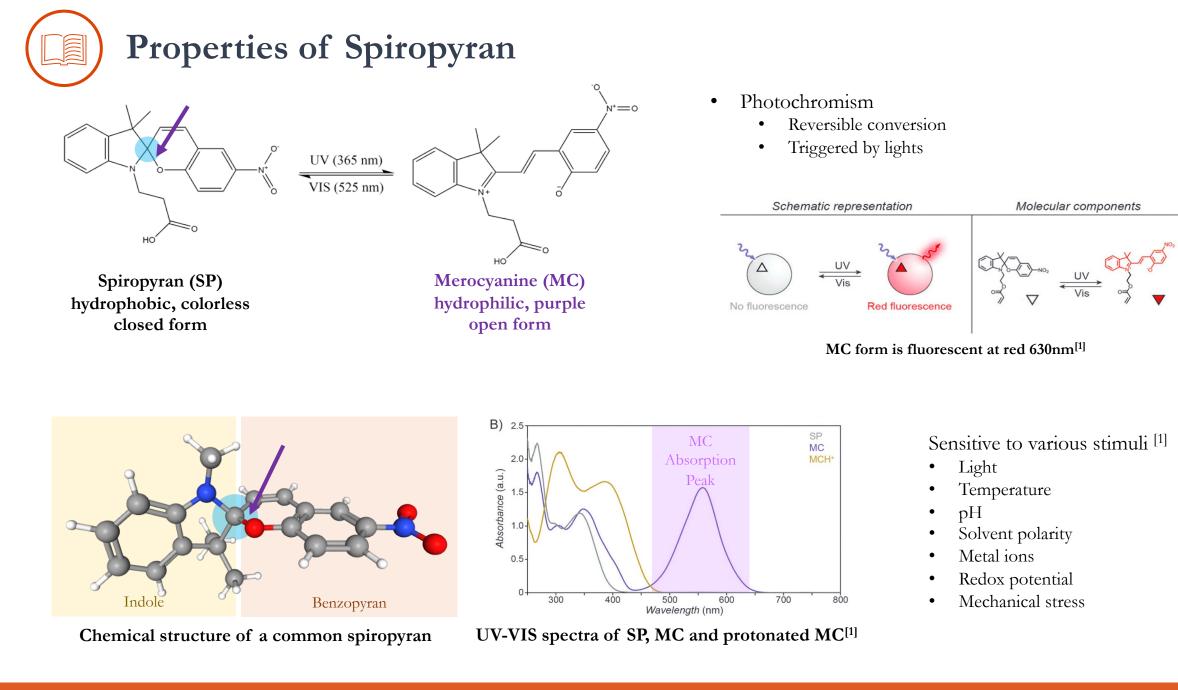
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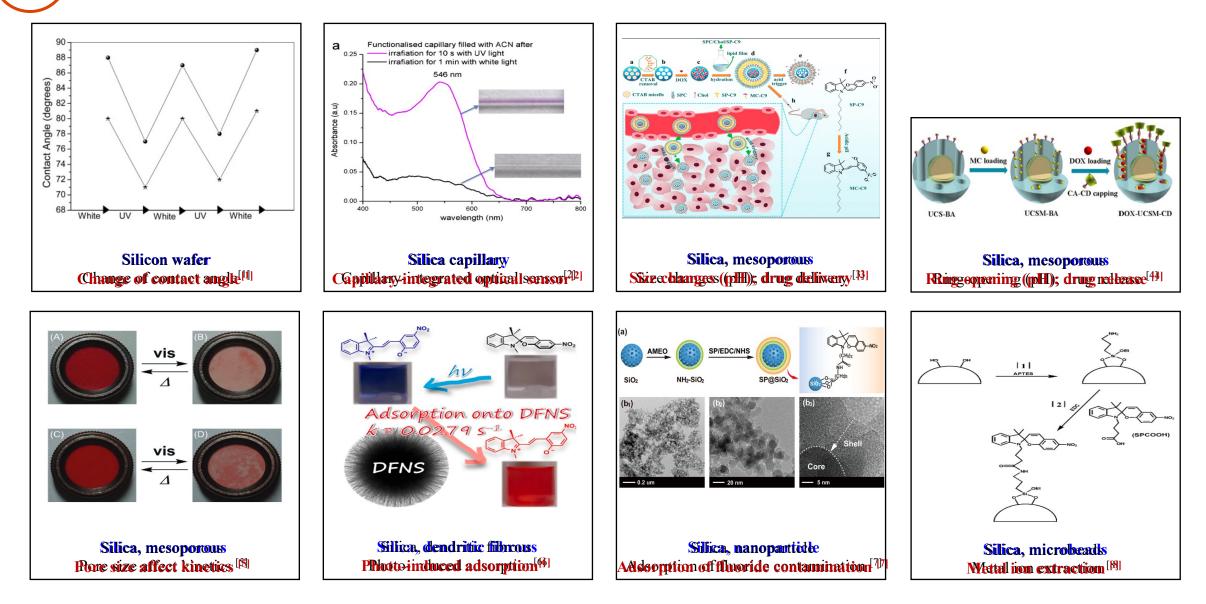
MICRO-TECHNOLOGIES REALIZED





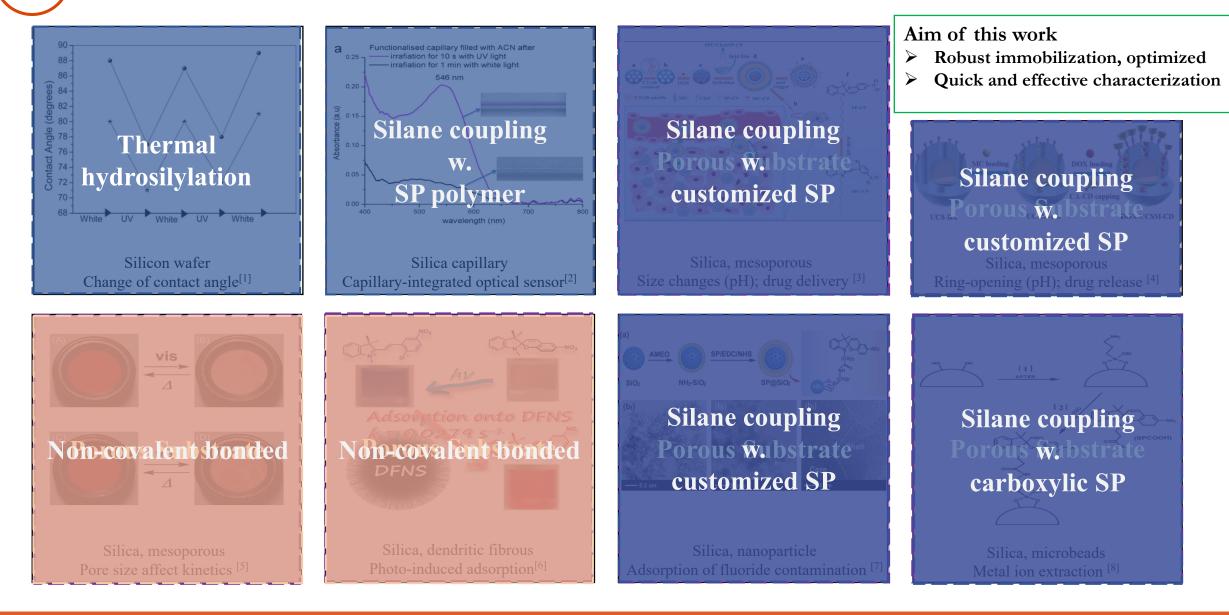


Spiropyran Applications with SiO₂



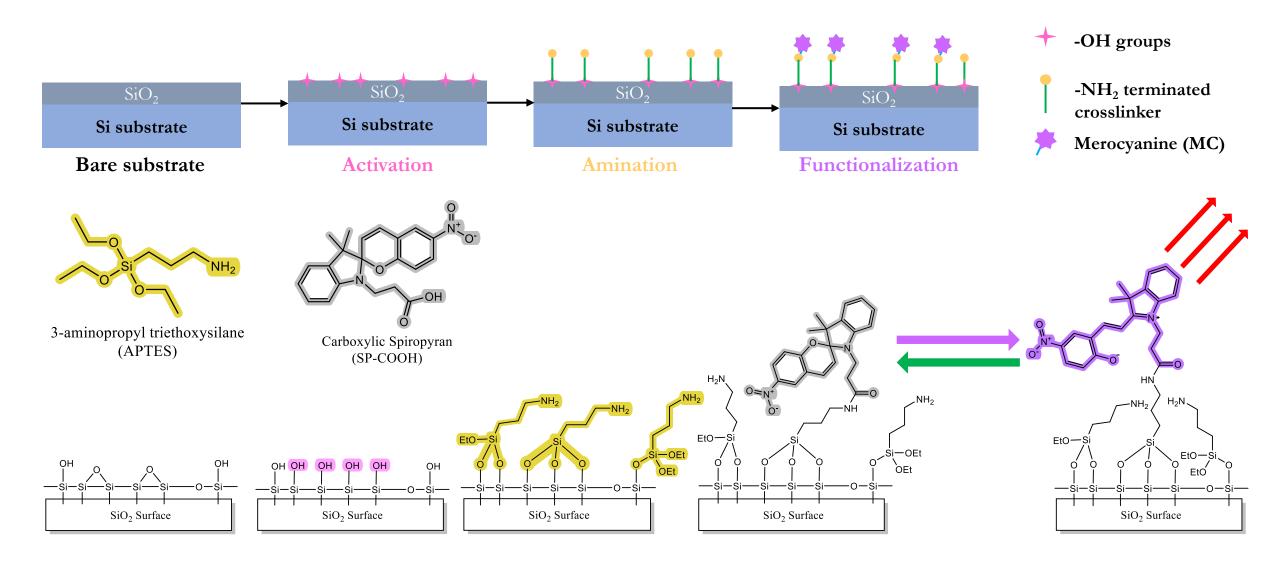
Substrates and Applications

Spiropyran Applications with SiO₂



Substrate Types and Bonding Methods







Surface Atomic Concentration by XPS and Contact Angle Activation Step

O 1s

Si 2p

Contact Angle

C 1s

> 3-aminopropyl triethoxysilane (APTES)

SiO₂ Surface

OH

OH

Selected Activation Methods

- . Oxygen plasma treatment
- 2. Acid treatment (1M HCl)
- Piranha solution: $(H_2SO_4 + H_2O_2)$

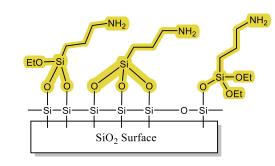
					-
Untreated SiO ₂ Surface	2.8%	67.1%	30.1%	$60^{\circ} - 70^{\circ}$	
Activated with O ₂ plasma	3.8%	67.5%	28.8%	$10^{\circ} - 15^{\circ}$	
Activated with HCl	2.8%	67.6%	29.6%	$10^{\circ} - 15^{\circ}$	
Activated with H ₂ SO ₄	2.7%	67.6%	29.7%	10° - 15°	

C ₉ H ₂₃ NO ₃ S	<mark>ii</mark>	Surface Atomic Concentration Table by XPS Amination Step					C9H23 <mark>N</mark> O3 <mark>Si</mark>
NH ₂	Amination Process Condition	C 1s	O 1s	Si 2p	N 1s	% organosilicon*	N : % organosilicon
-OEt	2% APTES 5min@RT	22.4%	50.7%	24.1%	2.8%	2.7%	1.0
)Et)	2% APTES 10min@RT	40%	36.9%	18.0%	5.1%	4.7%	1.1

*: from the immobilized APTES

EtO

Immobilization: thin layer of APTES amination



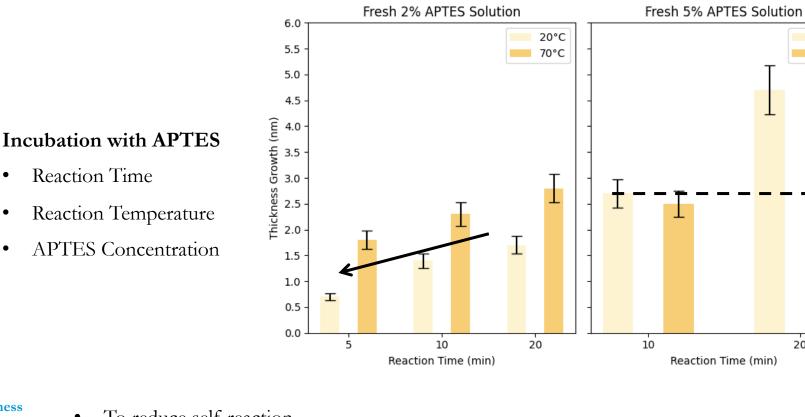
Thin layer, ideally mono-layer

SiO₂

Si substrate

Ellipsometry Model

Incident light



ΔThickness •

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Reflected light

- To reduce self-reaction
 - Freshly prepared APTES solution
 - 2% APTES at room temperature for $5\min \rightarrow 0.5 0.7$ nm
- From XPS results, N:% organosilicon is approximately 1:1. ٠
- Together, the results verifies a successful thin layer amination. ٠

20°C

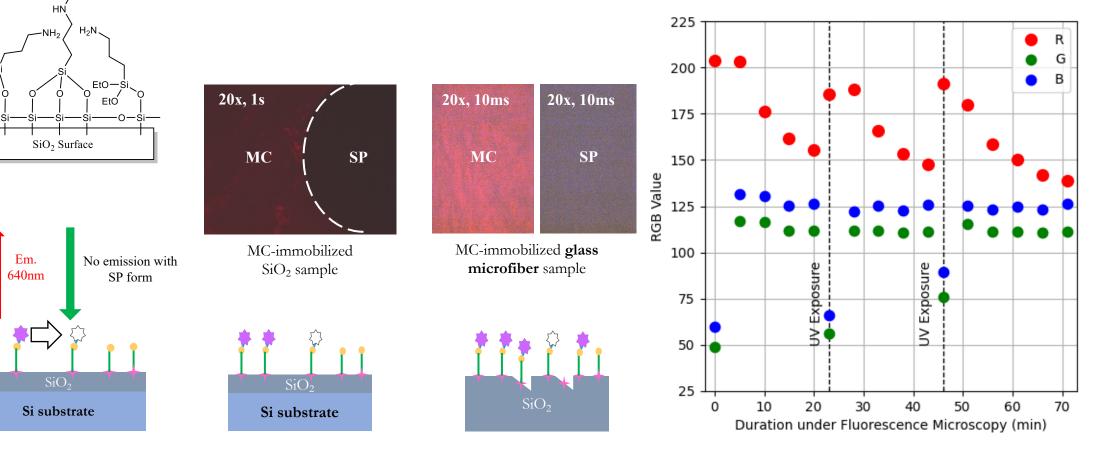
70°C

20

Immobilization: functionalized surface with fluorescence

Incubation with SP-COOH and EDC

- EDC-mediated coupling of carboxylic acids and amines
- Extracting RGB value from fluorescence images, taken at setting of 20x, 20ms



EtO-

Ex.

550nm

Ó

Summary and Future Work

- ✓ Immobilization Protocol
 - ✓ Effective activation
 - \checkmark Thin layer amination
 - \checkmark Fluorescence functionalization
- Characterization Protocol: XPS, contact angle, ellipsometry, fluorescence
 Change in surface chemistry / surface energy
 - ✓ Controlled thickness growth
 - \checkmark Reversible photo-patterning and fluorescence

Surface density of functional groups

 \blacktriangleright -OH is limited by surface type

≻On average, there are 4.9 #/nm² OH groups on amorphous silica.^[1]

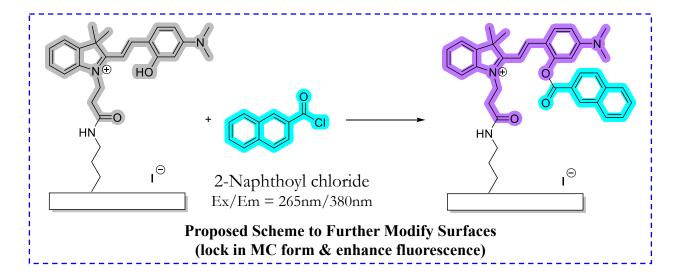
➢Sensitivity of fluorescence detection

► Measurement setup

Discussion

 \Box MC-SP conversation

□ Low quantum yield of MC fluorescence





Review Paper

[1] R. Klajn, "Spiropyran-based dynamic materials," Chem. Soc. Rev., vol. 43, no. 1, pp. 148–184, 2014, doi: 10.1039/c3cs60181a.

Spiropyran Application with SiO_2 Surface

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[3] Y. He *et al.*, "pH-Responsive size-shrinkable mesoporous silica-based nanocarriers for improving tumor penetration and therapeutic efficacy," *Nanoscale*, vol. 14, no. 4, pp. 1271–1284, 2022, doi: <u>10.1039/D1NR07513F</u>.

[4] R. Han, S. Wu, K. Tang, and Y. Hou, "Facilitating drug release in mesoporous silica coated upconversion nanoparticles by photoacid assistance upon near-infrared irradiation," *Advanced Powder Technology*, vol. 31, no. 9, pp. 3860–3866, Sep. 2020, doi: <u>10.1016/j.apt.2020.07.025</u>.

[5] T. Yamaguchi, N. N. Leelaphattharaphan, H. Shin, and M. Ogawa, "Acceleration of photochromism and negative photochromism by the interactions with mesoporous silicas," *Photochem Photobiol Sci*, vol. 18, no. 7, pp. 1742–1749, Jul. 2019, doi: 10.1039/c9pp00081j.

[6] T. Yamaguchi, A. Maity, V. Polshettiwar, and M. Ogawa, "Photochromism of a Spiropyran in the Presence of a Dendritic Fibrous Nanosilica; Simultaneous Photochemical Reaction and Adsorption," J. Phys. Chem. A, vol. 121, no. 42, pp. 8080–8085, Oct. 2017, doi: 10.1021/acs.jpca.7b08466.

[7] X. Guan, M. He, J. Chang, Z. Wang, Z. Chen, and H. Fan, "Photo-controllability of fluoride remediation by spiropyran-functionalized mesoporous silica powder," *Journal of Environmental Chemical Engineering*, vol. 9, no. 1, p. 104655, Feb. 2021, doi: <u>10.1016/j.jece.2020.104655</u>.

[8] S. Scarmagnani et al., "Photoreversible ion-binding using spiropyran modified silica microbeads," IJNM, vol. 5, no. 1/2, p. 38, 2010, doi: 10.1504/ijnm.2010.029921.

Limitation on -OH Surface Density

[1] L. T. Zhuravlev, "Concentration of hydroxyl groups on the surface of amorphous silicas," Langmuir, vol. 3, no. 3, pp. 316–318, May 1987, doi: 10.1021/la00075a004.



Oregon State

University

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Q & A

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THANK YOU

